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Complete if Known	
Application Number	09/945512
Filing Date	August 30, 2001
First Named Inventor	Forbes, Leonard
Group Art Unit	2812
Examiner Name	Booth, Richard
Attorney Docket No: 1303.027US1	

Sheet 1 of 1

US PATENT DOCUMENTS

Examiner Initial *	USP Document Number	Publication Date	Name of Patentee or Applicant of cited Document	Class	Subclass	Filing Date if Appropriate
RB	US-5,952,692	09/14/1999	Nakazato, K., et al.	257	321	10/28/1997
RB	US-6,210,999	04/03/2001	Gardner, , et al.	438	183	12/04/1998
RB	US-6,475,857	11/05/2002	Kim, W., et al.	438	240	06/21/2001
RB	US-6,541,280	04/01/2003	Kaushik, , et al.			03/20/2001

FOREIGN PATENT DOCUMENTS

Examiner Initial *	Foreign Document No	Publication Date	Name of Patentee or Applicant of cited Document	Class	Subclass	T*
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OTHER DOCUMENTS -- NON PATENT LITERATURE DOCUMENTS

Examiner Initial *	Cite No *	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T*
RB		SHI, Y., "Tunneling Leakage Current in Ultrathin (<4 nm) Nitride/Oxide Stack Dielectrics", IEEE Electron Device Letters, 19(10), (1998), pp. 388-390	
RB		ZHANG, "Atomic Layer Deposition of High Dielectric Constant Nanolaminates", Journal of The Electrochemical Society, 148(4), (2001), F63-F66	

EXAMINER

Richard A. Booth

DATE CONSIDERED

1/18/05

Substitute Disclosure Statement Form (PTO-1442)
 * EXAMINER: Initials & reference considered, whether or not citation is in conformance with MPEP 608. Date line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. Applicant's unique citation designation number (optional) & Applicant is to place a check mark here if English language Translation is attached.